

ABSTRACT

An anti-reflective and anti-static multilayer structure for display device, comprising a glass substrate, and an ITO layer, a first Nb₂O₅ layer, a first SiO₂ layer, a second Nb₂O₅ layer and a second SiO₂ layer, which are successively formed on the glass substrate, achieves good film adhesive strength, solidity and enhanced photoreflectance.